



Diffusion Model of Nonlinear HPM Effects in Advanced Electronics

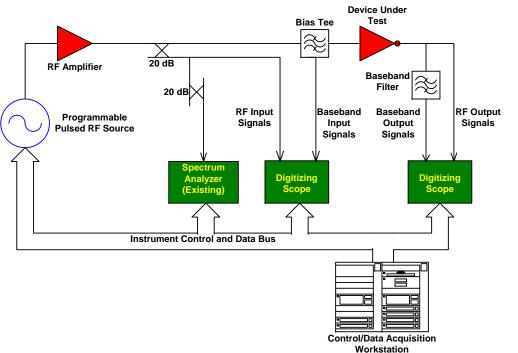
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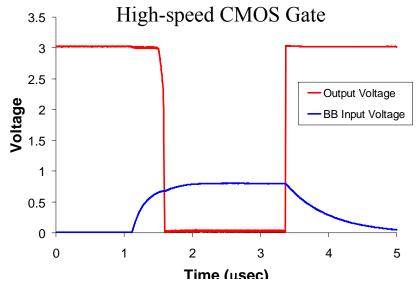
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Outline

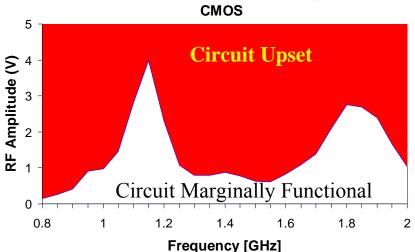
- Overview of results and contributions by UMD HPM Effects Research Group to the MURI Program
 - Results of experimental measurement and characterization of HPM effects at the device and circuit levels.
 - Investigation of effects from complex HPM waveforms
 - HPM effects in electronic networks and systems.
- Model of HPM effects in semiconductor circuits
 - Complement to RCM analysis of complex structures
 - Simple, scalable and based on physical device parameters
 - Compatible with existing high-frequency circuit simulators
 - Accurate predictor of susceptibility in existing and advanced circuits and systems

Effects Testing of Integrated Circuits



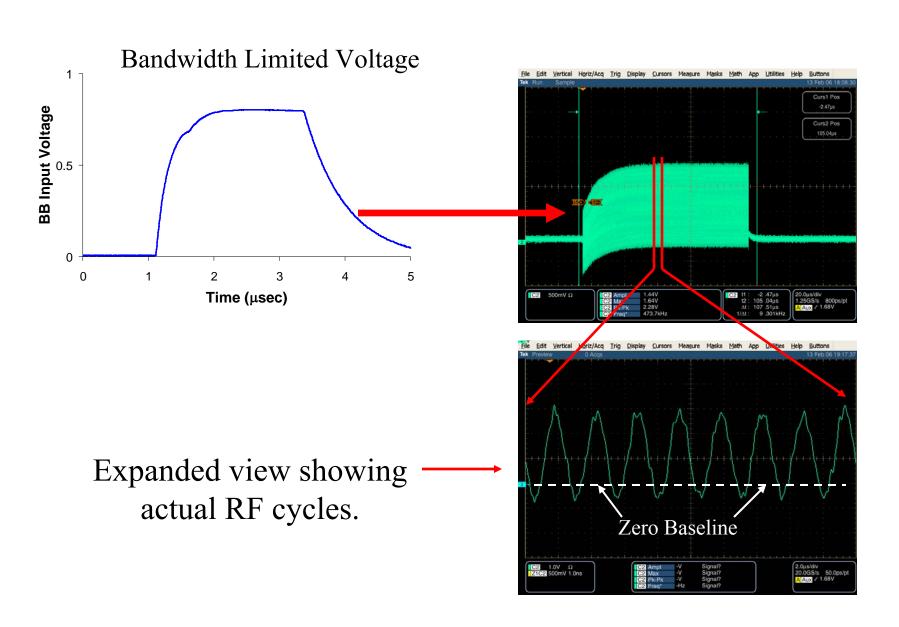


- •Onset of effects $0.25 \le V_{RF} \le 1 \text{ V}$
- •Depend on RF frequency, pulse width, modulation, logic state, bias voltage, bus impedances, surrounding circuitry....
- •Typically pulse widths > 100 nsec are required

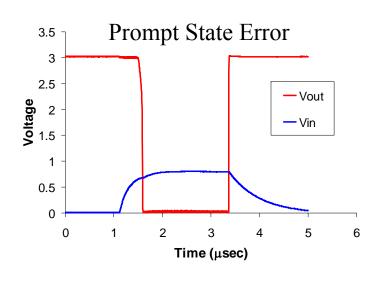


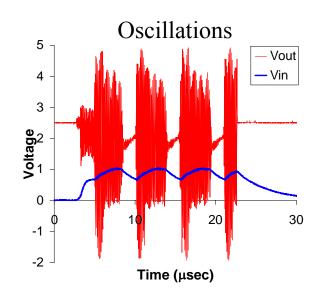
Upset Threshold vs. Frequency in High-speed

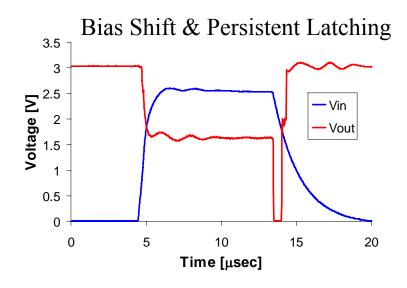
RF voltage at the input of a typical CMOS

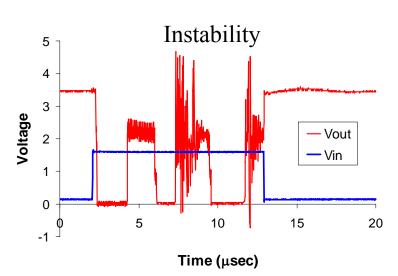


Examples of Effects in Advanced CMOS

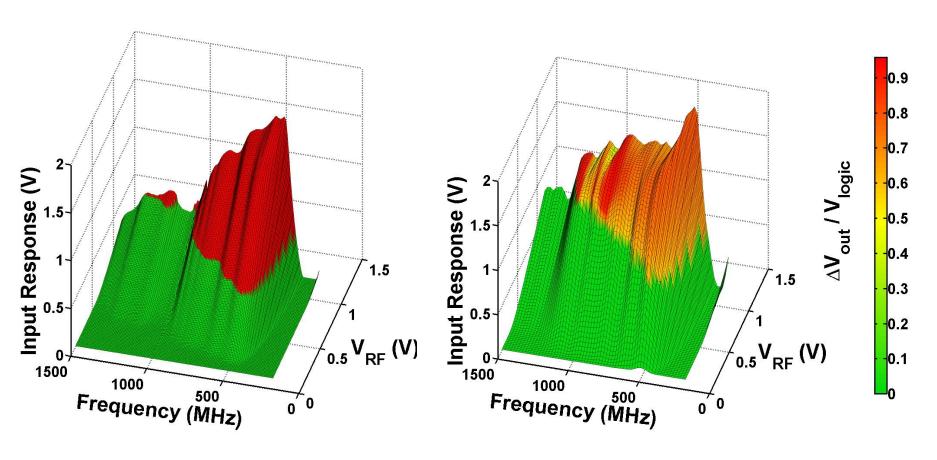






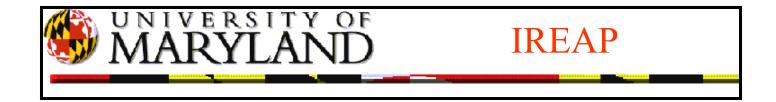


Mapping RF effects in integrated circuits

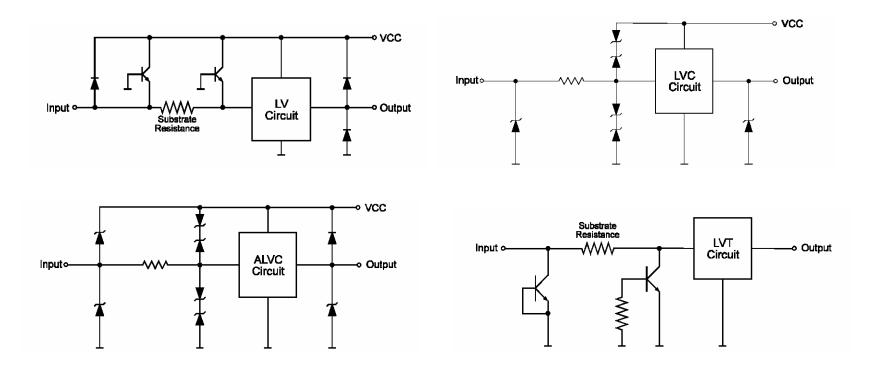


High-speed CMOS

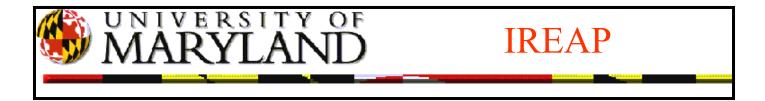
Advanced Low-voltage CMOS



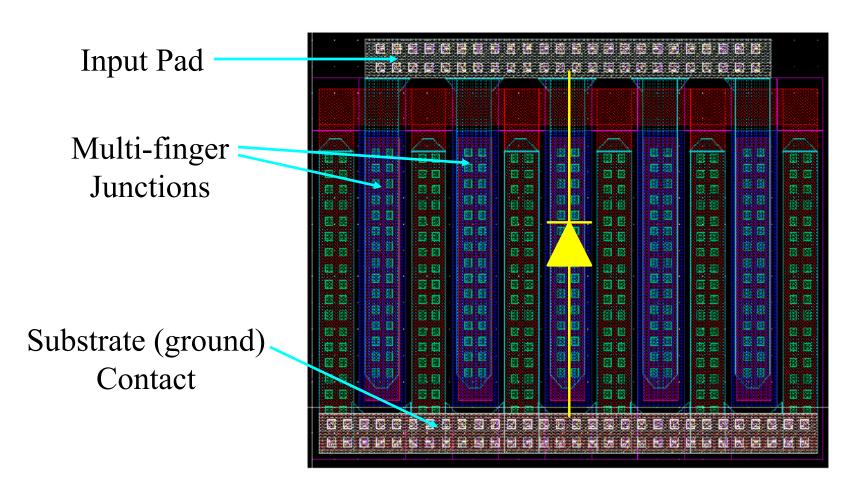
Examples of ESD protection in integrated circuits

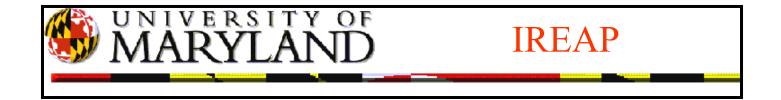


Electrostatic discharge protection devices are integrated into virtually all integrated circuits: discrete, logic, analog, RFIC, mixed signal

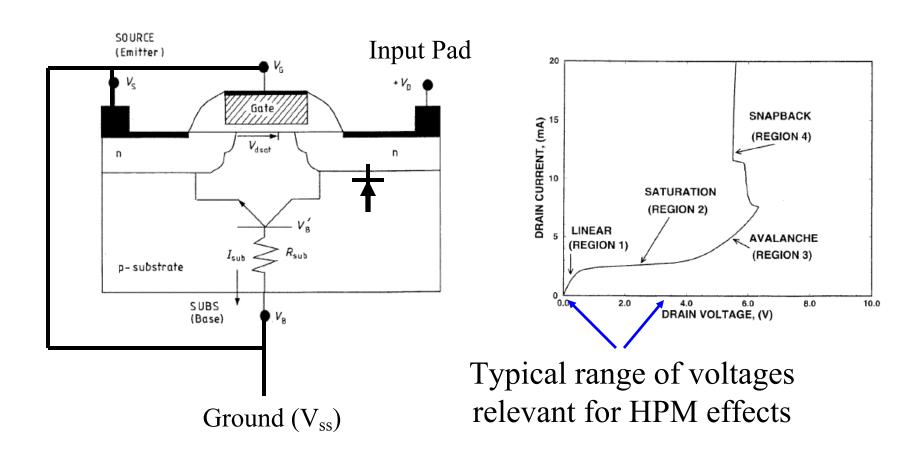


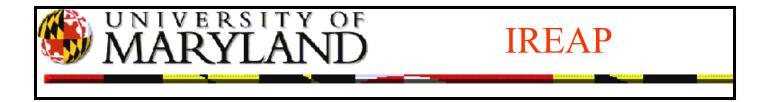
Physical Layout of ESD Protection Device



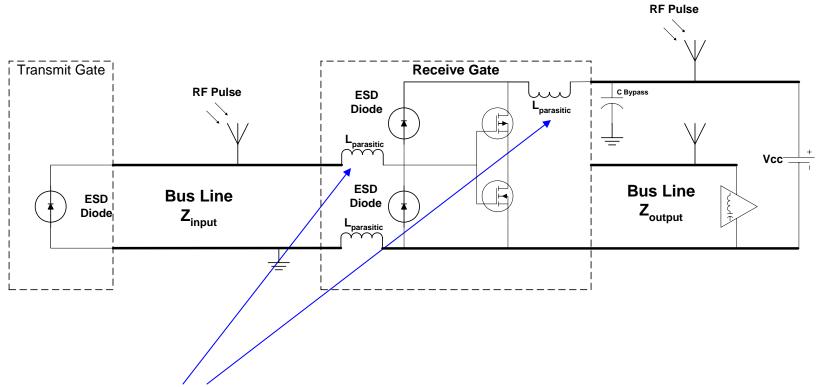


Electrical and Physical Characteristics of ESD Devices



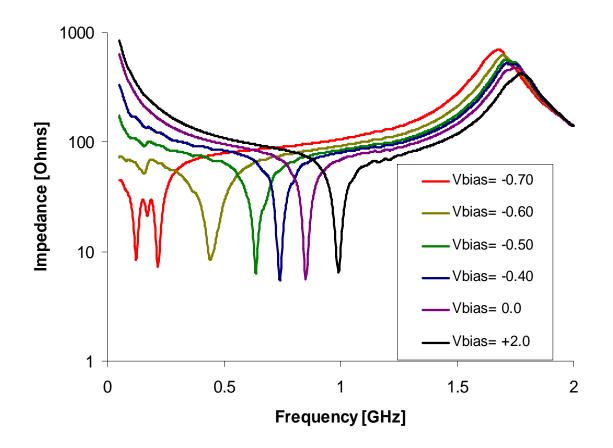


Simplified Schematic of a CMOS Circuit



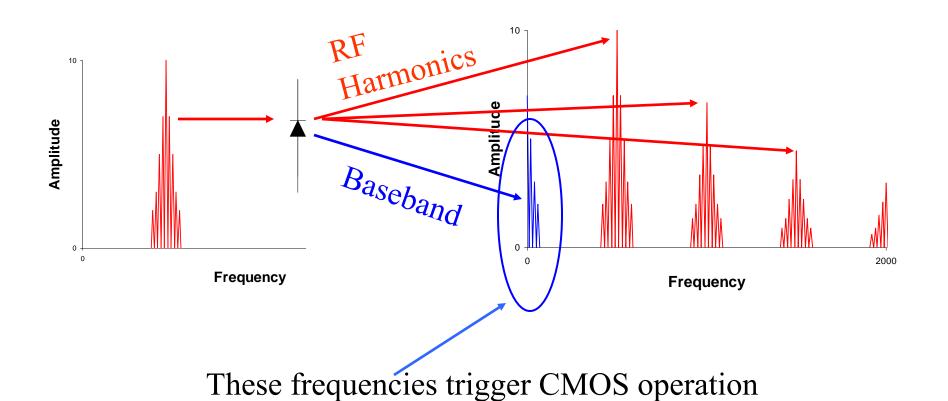
Resonant circuits consisting of lumped and distributed parasitic elements

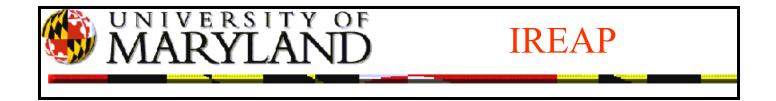
Impedance at the input of high-speed CMOS logic circuit



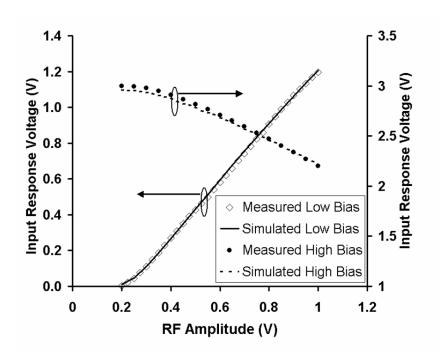
•When driven at resonance, the diode current and the rectified voltage increase.

The ESD diodes down-convert the modulation frequencies off the microwave carrier





Comparison of measured and simulated response using model parameters extracted from small-signal measurements

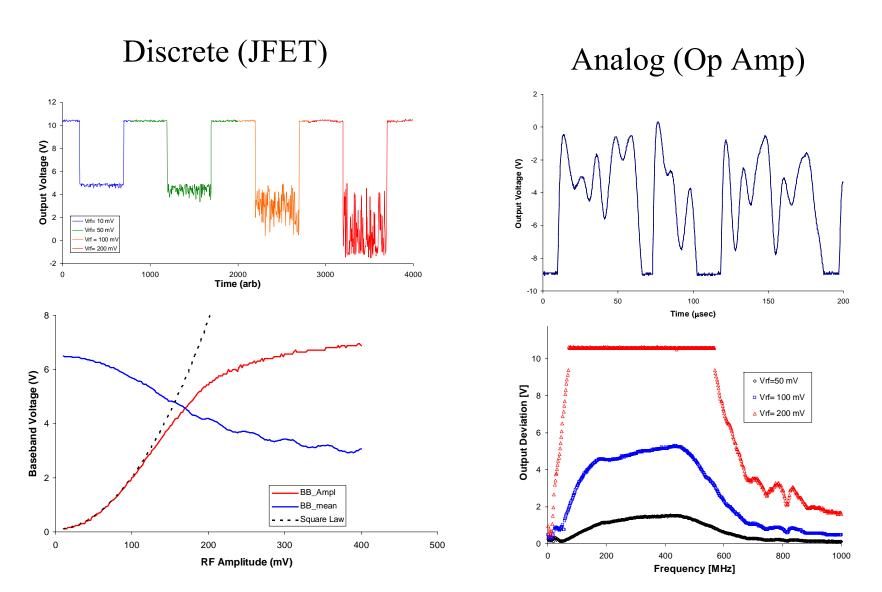


2.0 2.6 1.8 2.4 Measured Low Bias Simulated Low Bias · Measured High Bias 1.2 0.2 Simulated High Bias 0.0 1.0 0.2 1.2 1.4 0.6 0.8 Input RF Amplitude (V)

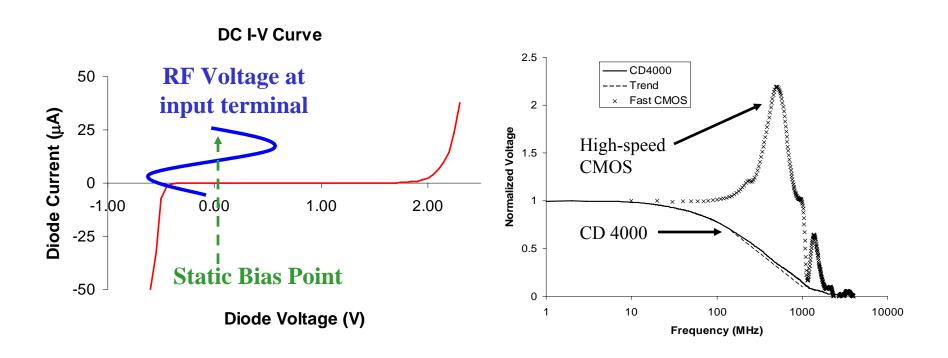
High-speed CMOS Logic

Advanced Low-voltage CMOS

This behavior has been observed and studied in a wide variety of circuits.

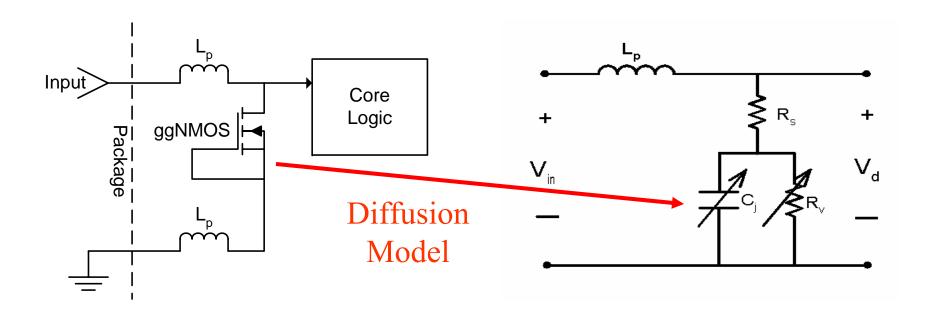


Are these parasitic diodes good rectifiers at microwave frequencies (f > 300 MHz)?



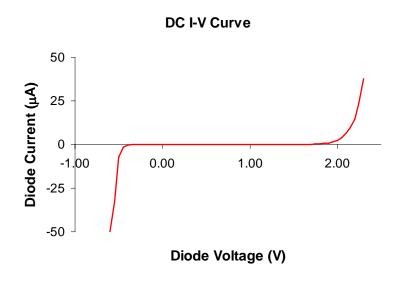
- W. Crevier, "Rectification Equivalence: A method for characterizing semiconductor rectification," *Titan-Jaycor internal report to DTRA*, December, 1996.
- •M. L Forcier, R. E. Richardson, "Microwave rectification RFI response in field-effect transistors," *IEEE Trans. Electromag. Comp.*, vol. EMC-21, no. 4, Nov. 1979.
- •D. J. Kenneally, G. O. Head, S. C. Anderson, "EMI noise susceptibility of ESD protect buffers in selected MOS devices," *Proc. IEEE Int. Conf. Electromag. Comp.*, Wakefield, MA, August, 1985, pp. 251-261.

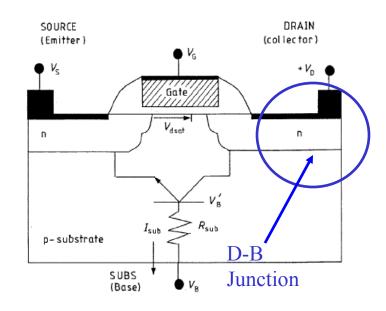
The "rectification" model does not a complete the picture



Model of Drain-Bulk Diode in CMOS

High-Frequency Analysis of D-B Junctions



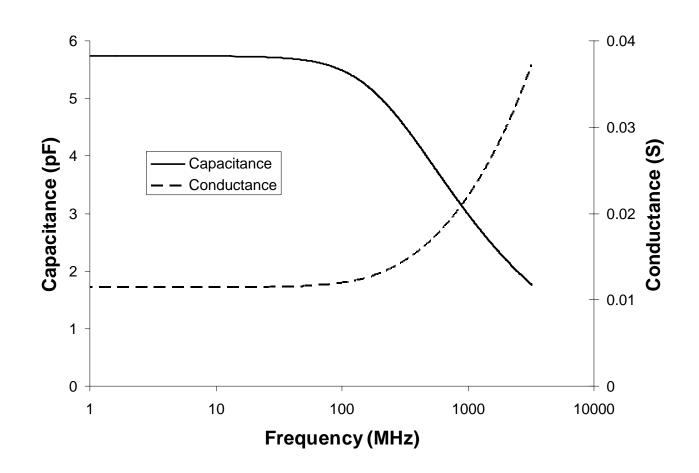


$$\frac{\partial \Delta p(x,t)}{\partial t} = D_p \frac{\partial^2 \Delta p(x,t)}{\partial x^2} - \frac{\Delta p(x,t)}{\tau}$$
Time-dependent Diffusion Equation

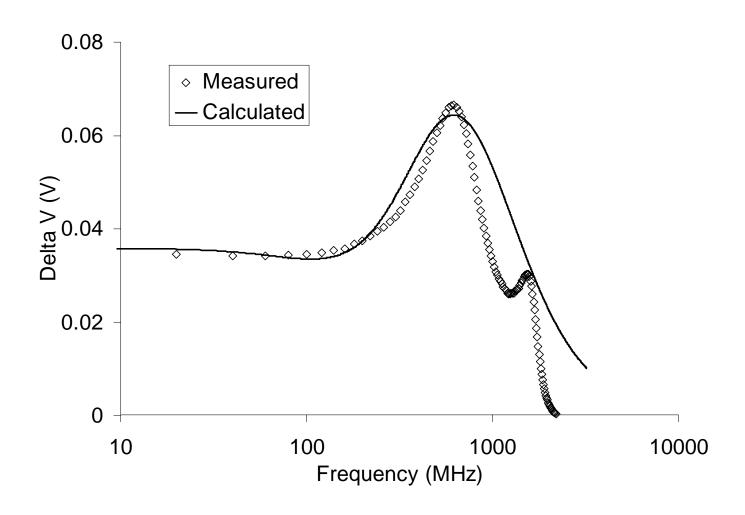
$$I_{diff} = qA \frac{D_p}{L_p} \frac{n^2}{N_D} (e^{\frac{qV_d}{kT}} - 1)$$
 Solution for "Abrupt" Boundary Conditions

$$Y_D = \frac{i_D}{v_D} = G\sqrt{1+j\omega\tau}$$
 High-frequency Admittance

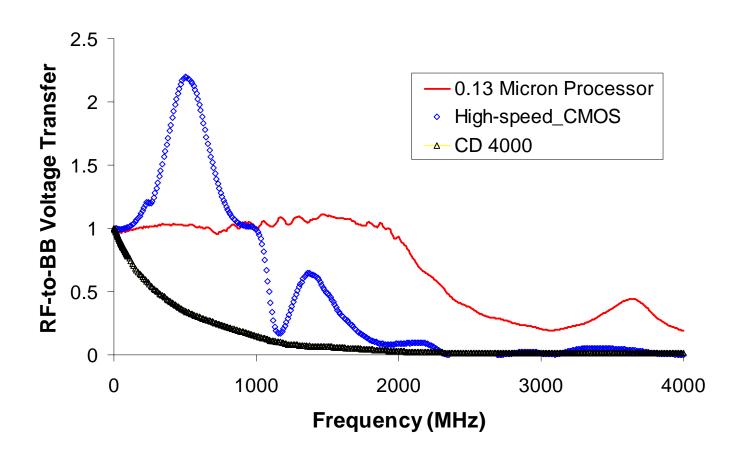
High-Frequency Admittance of D-B Junctions $(I_s = 10^{-15} \text{ A}, V_{th} = 0.025 \text{ V}, \tau = 5 \text{ nsec})$



Comparison of measured and calculated D-B sensitivity in advanced low-voltage CMOS ($\tau = 5$ nsec)



Comparison of the D-B junction sensitivity in micronscale logic

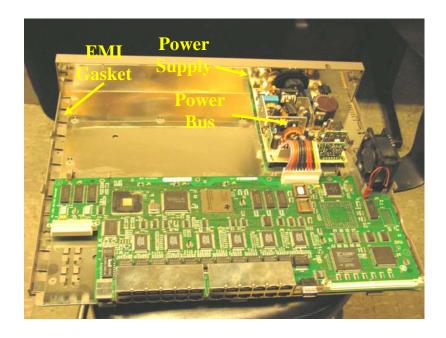


Overview of studies of HPM upset in electronic systems

- •Systems consist of many circuits with internal resonances interconnected by transmission lines within complex cavities.
- •What parts of the system are most likely to be upset once RF penetrates the enclosure?







Chassis cover removed

Distribution of parasitic resonant frequencies and quality factors in a digital communications system

View of the IC layout on the motherboard of a programmable LAN switch



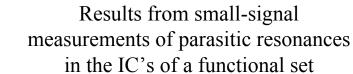
I/O

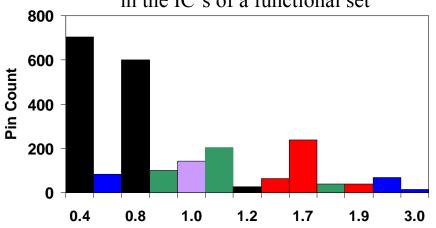
Logic

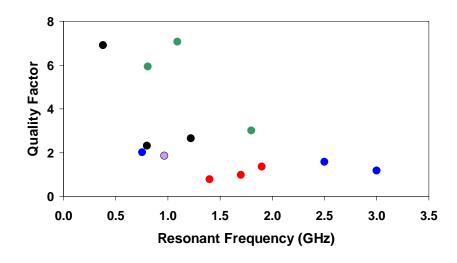
System Controller

CPU

Memory

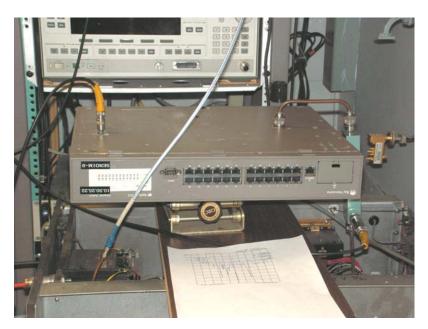






Characteristics of electronic systems

- Most electronic systems contain modular components that are packaged according to standardized form factors (4U, 19" bays, ATX, etc.)
- •Does this present any universal conditions or likely avenues for HPM attack?
- •The enclosures are clearly natural microwave resonators.



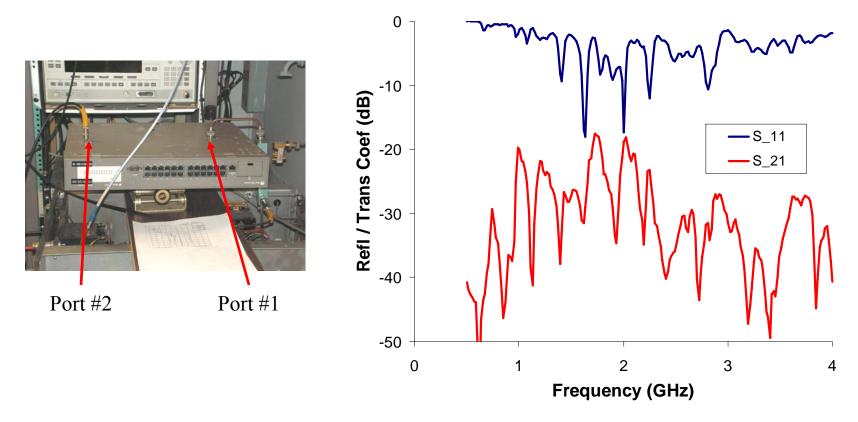
LAN switch with coaxial RF ports



PC with waveguide port

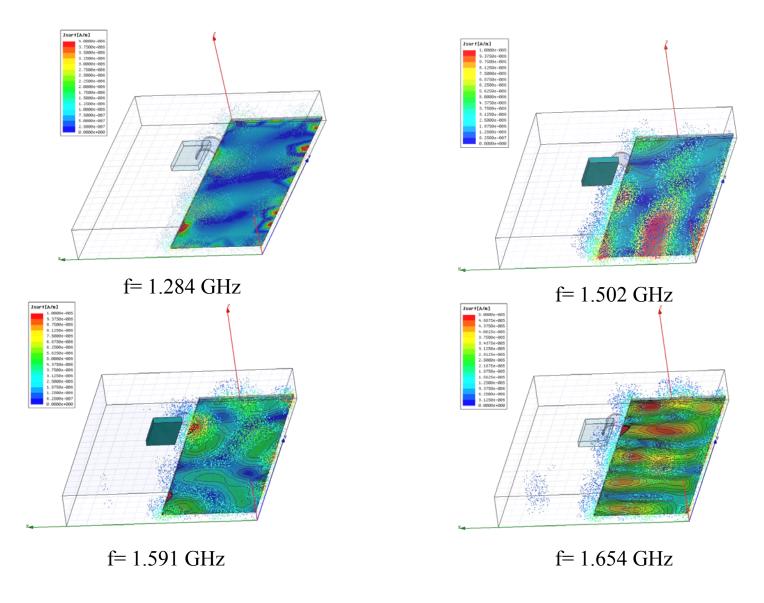
Results of S-parameter measurements in an operating LAN switch

- Port #1 is a dipole launching antenna and port #2 is connected to the main
- +12 VDC power bus on the motherboard

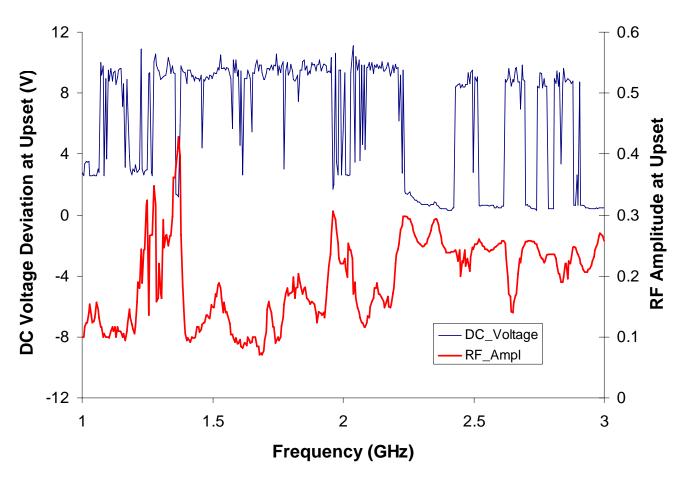


• Strong resonances are observed across L-band (~1-2 GHz)

RF Surface Current Density for Various TEM Eigenmodes on the Motherboard



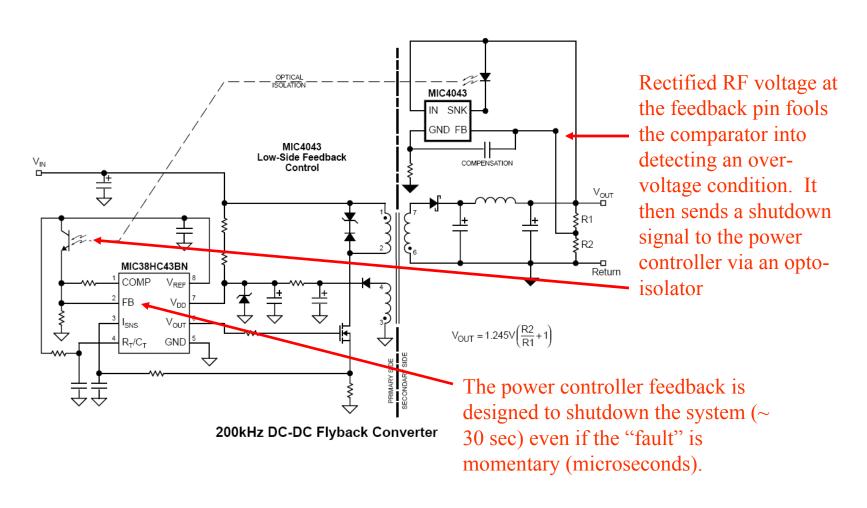
Results from Upset Studies in a LAN Switch



- •At upset, the RF caused the switching power supply to either completely shut down or output the incorrect voltage for times that were 100 1000 times the RF pulse width.
- •This forced the microcontroller to completely reboot the system.



Schematic of a typical switching power supply

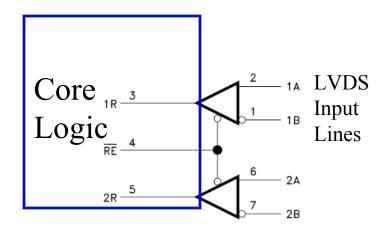


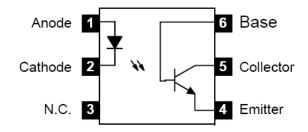
Conclusions

- RF rectification by ESD protection diodes and parasitic resonances have been identified as major susceptibility issues.
- The RF characteristics of these devices can be accurately described using lumped-element circuit models with simple high-frequency diode parameters.
- Upset can be easily predicted in terms of the high-frequency transfer characteristics of the circuit and the RF voltage, frequency and modulation at the circuit terminals.
- In systems, the problem requires an EM or RCM treatment.
- Power controllers with feedback have been identified as a major and universal problem.
- An informed basis for developing effects sources:
 - L-band
 - Wideband or chaotic modulation
 - 10-100 MW Power levels

Possible Solutions

- Low-voltage differential signaling between critical communications nodes
- New concepts for optoisolation, low-power diodes, single photon detectors, etc.
- Power supply redesign
- New ESD circuits and structures





Students and Academics

- •Student Research Assistants: Kathryn Chang, R. Mac Laren,
- •Sponsored research: Calvin Cheung
- •REU Interns: L. Goodman, M. Adan, K. Konstantine, S. Vora,
- •UMD ENEE 499 Advanced Lab, "HPM Effects in Communications Electronics: B. Yeshitla, H. Lee, M. Stamm, M. Brill
- •UMD Gemstone Honors Program

Publications, Invited Talks, Mini-courses 2004-present

- 1. T.M. Firestone, J. Rodgers and V.L. Granatstein, "Response of CMOS Logic with Electrostatic Discharge Protection to Pulsed Microwave Excitation Submitted to IEEE Trans. on Circuits and Systems.
- 2. T. M. Firestone, "RF Induced Nonlinear Effects in High-Speed Electronics" Masters of Science Thesis, University of Maryland, May 2004.
- 3. J. Rodgers, T. Firestone, V. L. Granatstein, V. Dronov, T. M. Antonsen, Jr., and E. Ott, "Study and applications of wideband oscillations in high-power pulsed traveling-wave tubes," *Proceedings of the Sixth International Vacuum Electronics Conference IVEC* 2005, Noordwijk, The Netherlands, April 2005.
- 4. J. Rodgers, "HPM upset in communications systems," Invited talk presented at the Defense Threat Reduction Agency workshop on Microwave Effects, Sept., 2005, Alb. NM.
- 5. J. Rodgers, "Nonlinear and chaotic effects in communications electronics from high-power microwave pulses," Invited one-day minicourse presented to Defense Intelligence Agency 09 August, 2005, Hunstville, AL.
- 6. J. Rodgers, "Stochastic microwave sources for effects applications," invited talk presented at the Defense Threat Reduction Agency workshop on Microwave Effects, Sept., 2005, Alb. NM.